

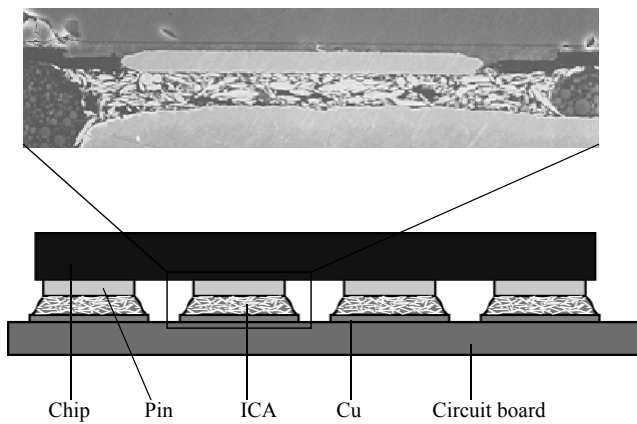
1.2. Assembly

1. **Print & Cure**
2. **Stud Bump applications**
3. **Polymer bumps**

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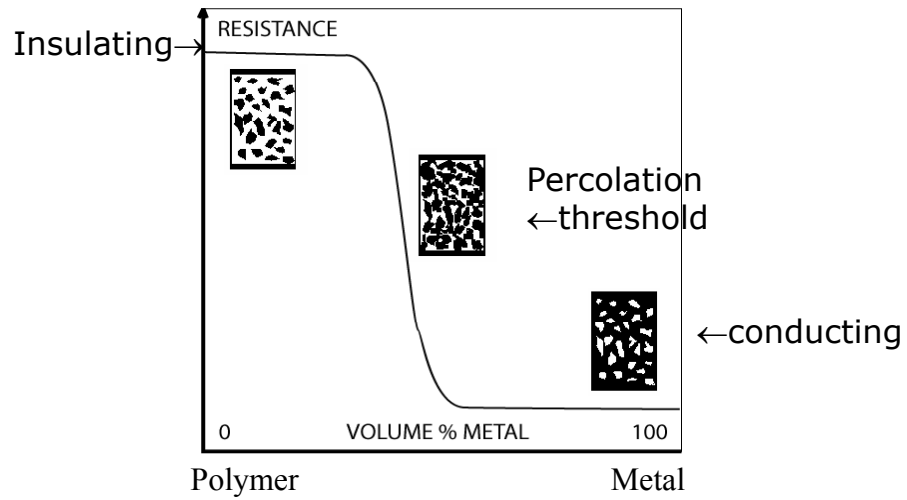
1.3 ICA Structure & Percolation



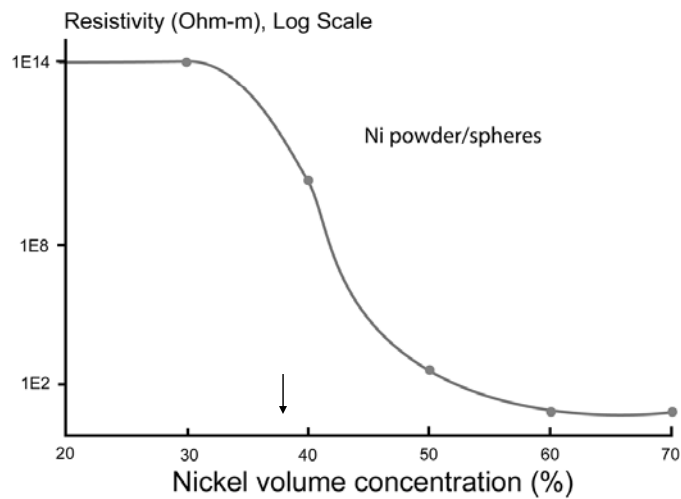
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ICA Percolation



Experimental Percolation



1.4 Properties Commonly used isotropic conductive adhesives

(Jagt, Chapter 11, Conductive adhesives for Electronics Packaging)

Adhesive & Type	Viscosity (Pa.s)	Potlife	Glass transition	Volume Resistivity Ωcm	Shear strength (MPa)	Curing time (min.)	Curing Temp. ($^{\circ}\text{C}$)
ICA 1 (1 comp.)	65	3 days	80	$2 \cdot 10^{-4}$	11	10-15	130-150
ICA 2 (2 comp.)	25-35	3-4 days	85	$1-4 \cdot 10^{-4}$	10	30	130-140
ICA 3 (2 comp.)	50	2 days	50	$2-4 \cdot 10^{-5}$	8	90	130-140
ICA 4 (1 comp.)	160-200	4 days	80	$5 \cdot 10^{-3}$	5	20-30	120-130
ICA 5 (1 comp.)	310-350	4 days	80	$1 \cdot 10^{-3}$	4	20-30	120-130
ICA 6 (2 comp.)	150-200	8-12 hr	75	$2-5 \cdot 10^{-4}$	14	10-15	170-180

Compare intrinsically conducting polymers,
 e.g. Polyaniline: $\rho = 10^5$ (intrinsic) to $10^{-2} \Omega\text{.cm}$ (doped)
 Compare Ag: $\rho_{\text{Ag}} = 1.6 \times 10^{-6} \Omega\text{.cm}$; $\rho_{\text{ICA}} = 12.5$ to $312.5 \times \rho_{\text{Ag}}$

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Properties of a typical ICA

Property	Values
Viscosity @ 25 $^{\circ}\text{C}$	55,000 cps
Work Life @ 25 $^{\circ}\text{C}$	2 weeks
Cure Condition	1 hour @ 150 $^{\circ}\text{C}$
Cure Option	1/2 hour @ 175 $^{\circ}\text{C}$
Volume Resistivity	$5 \cdot 10^{-4}$ ohm-cm
Glass Transition Temperature (T_g)	90 $^{\circ}\text{C}$
Coefficient of Thermal Expansion	Below T_g 55ppm/ $^{\circ}\text{C}$
	Above T_g 200ppm/ $^{\circ}\text{C}$
Thermal Conductivity	3.20W/mK @ 121 $^{\circ}\text{C}$

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1.5 ICA Problem History

- **Silver migration → polymer**
- **Electrical conductivity → silver**
- **Electrical stability → pad metallurgy**
- **Adhesive strength/shear strength**
- **Rework → thermoset/thermoplastic blend**
- **Impact resistance → Liu/Tong**
 - **Via fill → high density substrates**
- **Electrical conduction mechanism**
- **Self-alignment**

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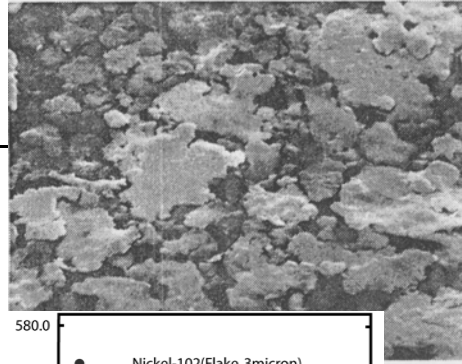
2. Filler Structure

- 2.1 Flakes
- 2.2 Bi-modal
- 2.3 Layering
- 2.4 Nanoparticles
- 2.5 Low Melting Point (LMP) Alloys
- 2.6 Self-alignment

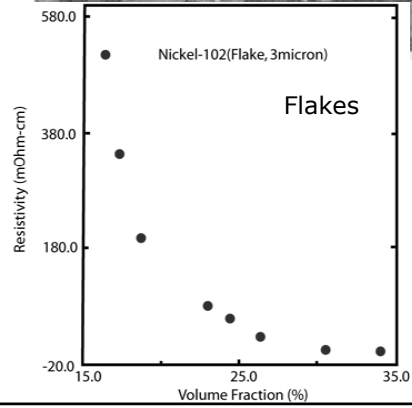
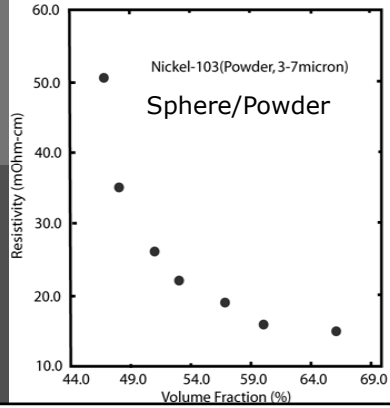
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2.1 Flakes: surface/vol ratio

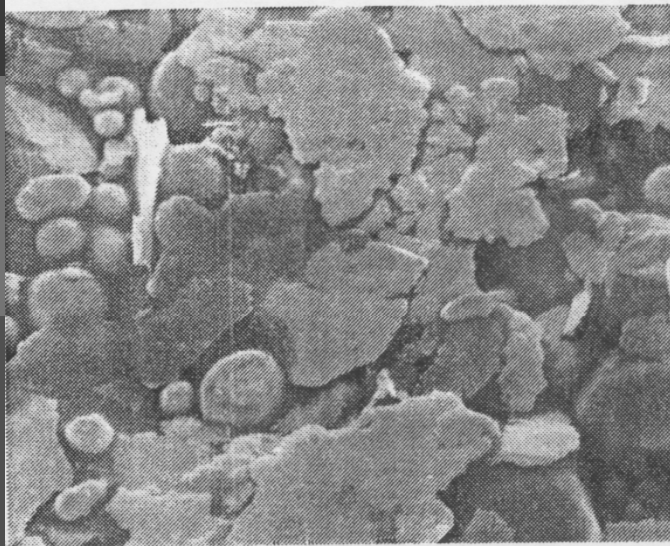


Percolation Threshold Comparison



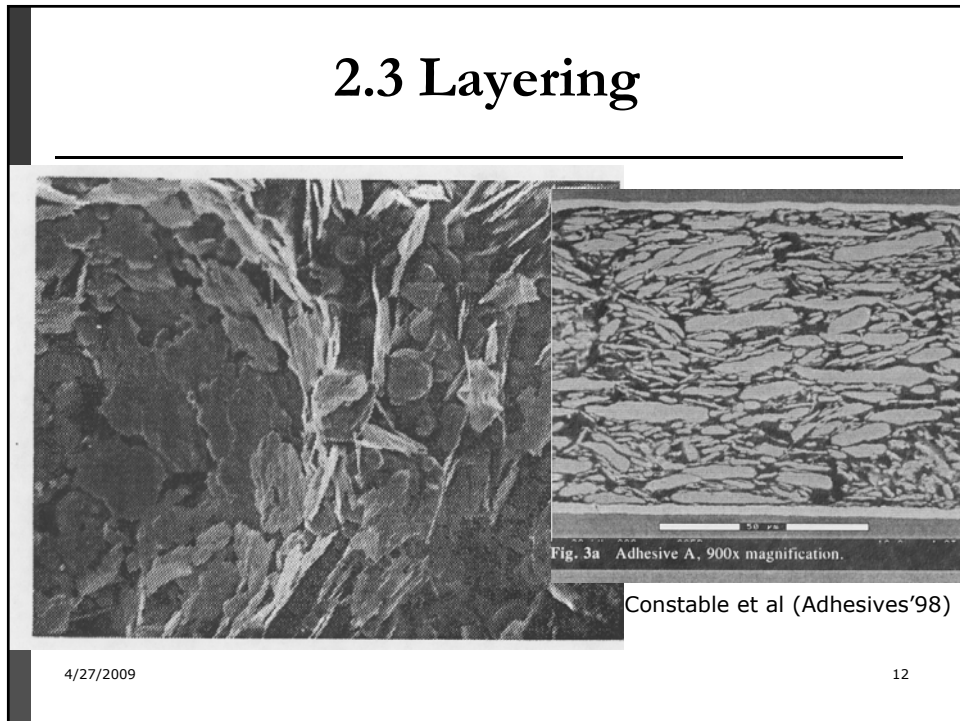
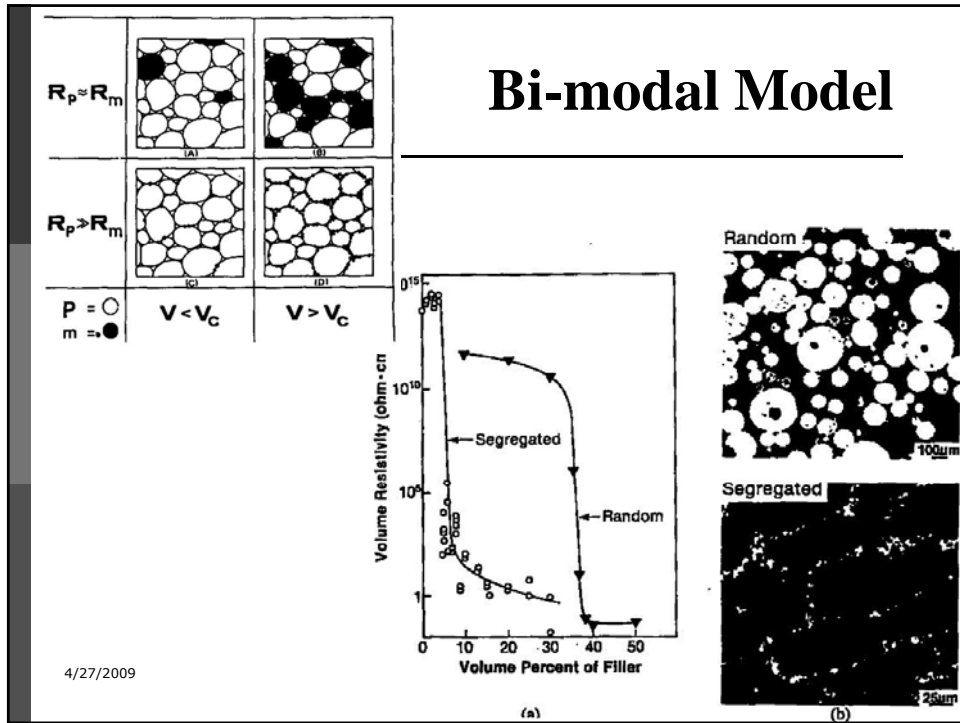
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2.2 Bi-modal: Flakes + powder

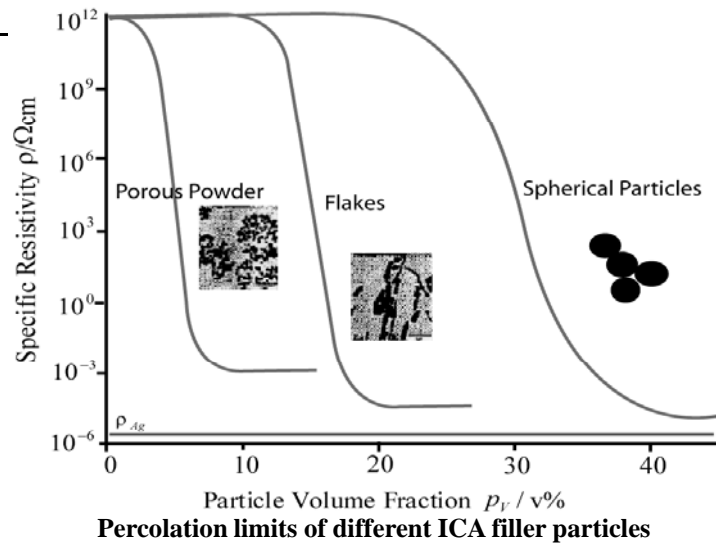


e.g.
10 μ m diameter flakes
(<1 μ m thick)
plus
1-3 μ m diameter powder
(spheres)

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2.4 Nanoparticles



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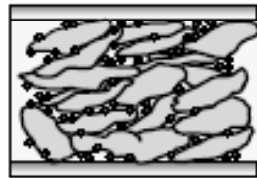
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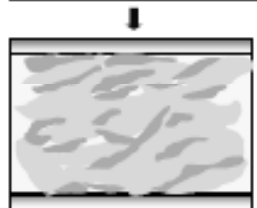
(a)

Nanoparticle Sintering

[Wong et al, ECTC'06]



(b)



(c)

Figure 1. Schematic of particles and flakes between the metal and pads. (a) is conductive adhesives with silver flakes as fillers; (b) is conductive adhesives with both flakes and nanoparticles as fillers; (c) is conductive adhesives with sintered particles among flakes as fillers.

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2.6 Self-alignment

(CP Wong)

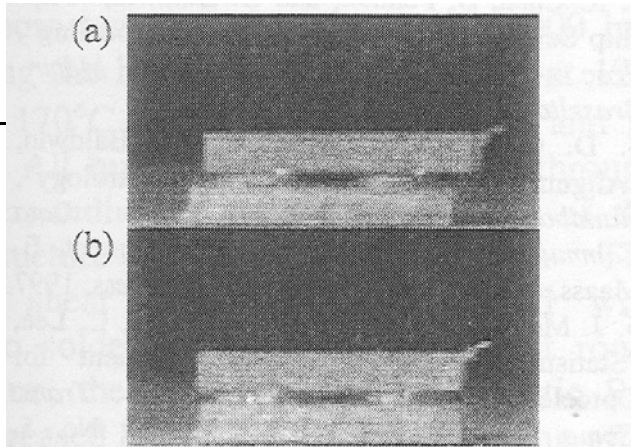


Figure 8 (a) Self-alignment test for ECAs filled with the LMA filler before the reflow and (b) after the reflow.

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Self-Alignment [Kim et al, Polytronic 2003] (Model)

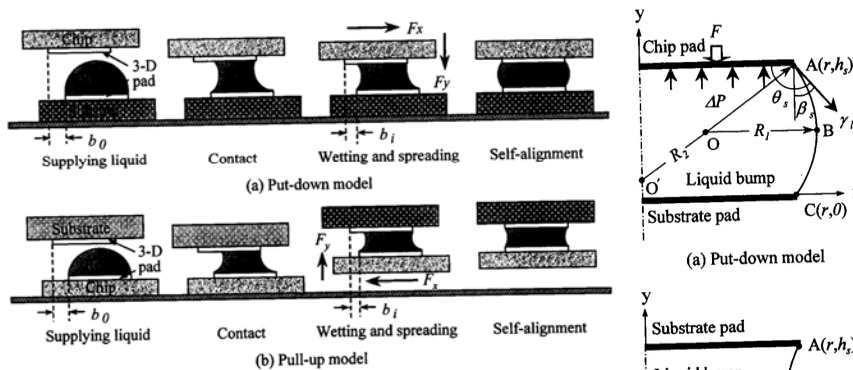


Figure 1. Principles of self-alignment processes using surface tension of resin material.

Table 1 Material properties of epoxy adhesive

Properties	Epoxy adhesive
Viscosity (Pa·s)	6.0
Surface tension (N/m)	0.035
Specific gravity	1.73
T _g (°C)	149
C.T.E (10 ⁻⁶ /°C)	19

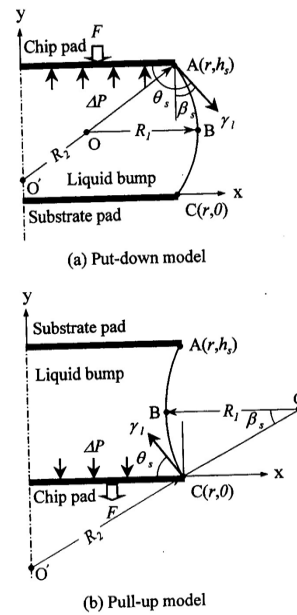
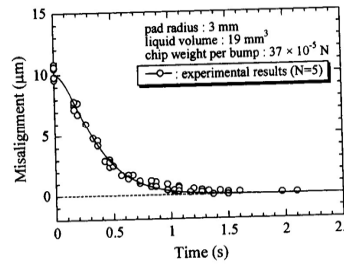


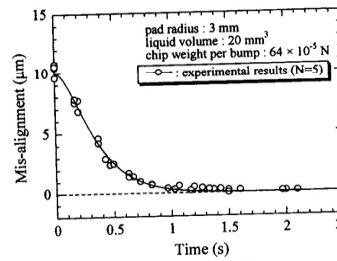
Figure 2. A single joint model.

Self-Alignment (Expt)

[Kim et al, Polytronic 2003]



(a) Put-down model



(b) Pull-up model

Figure 5. Self-alignment behavior.

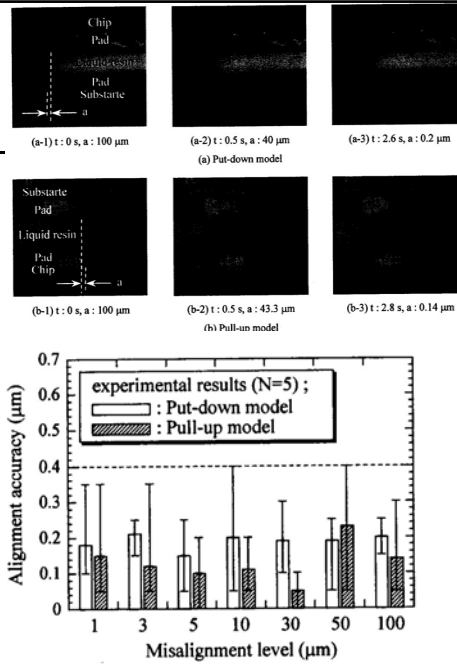


Figure 7. Alignment accuracy at different levels of misalignments.

3. ICA Cure

- 3.1 Resistance change with cure
- 3.2 Cure model
- 3.3. Shrink vs. cure
- 3.4 Cure optimization
- 3.5 Microwave cure

3.1 Resistance Change

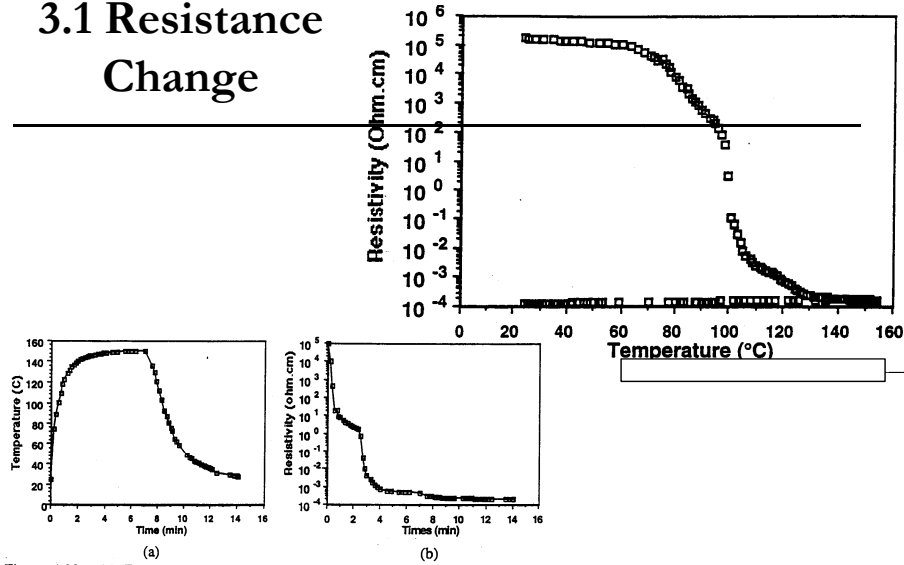
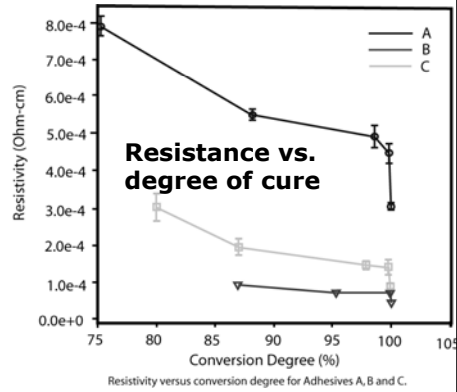
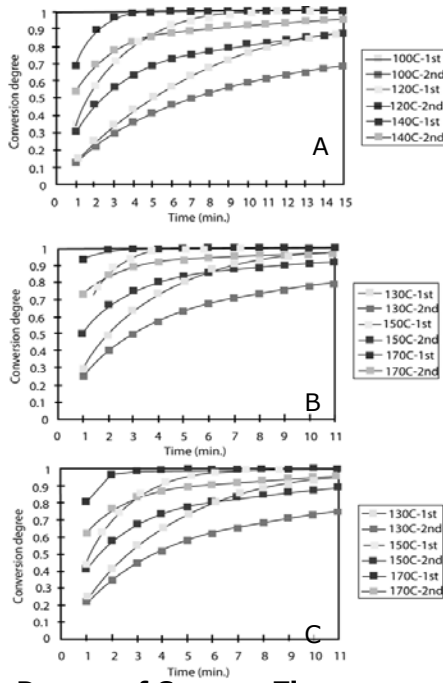


Figure 4.20: (a) Temperature profile for 3 minutes isothermal cure at 150°C. (b) Resistivity change during isothermal cure at 150°C for Adhesive C.

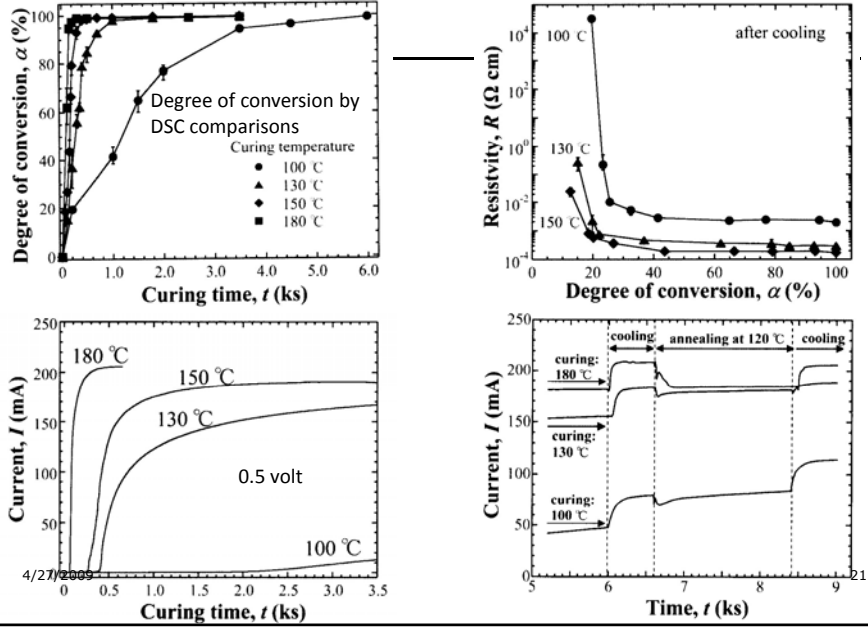
Figure 4.20: (a) Temperature profile for 3 minutes isothermal cure at 150°C. (b) Resistivity change during isothermal cure at 150°C for Adhesive C.

3.2 Cure Modeling: 3 Adhesives

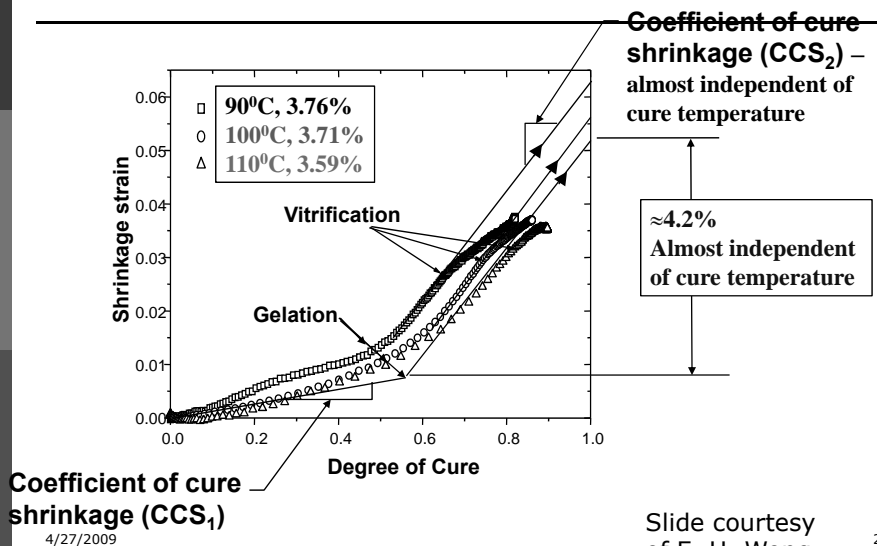


Simple 1st order cure models work well
 Manufacturer profiles → incomplete cure

Degree of Cure vs. Time



3.3 Cure Shrinkage/Degree of Cure Characteristics



Slide courtesy of E. H. Wong

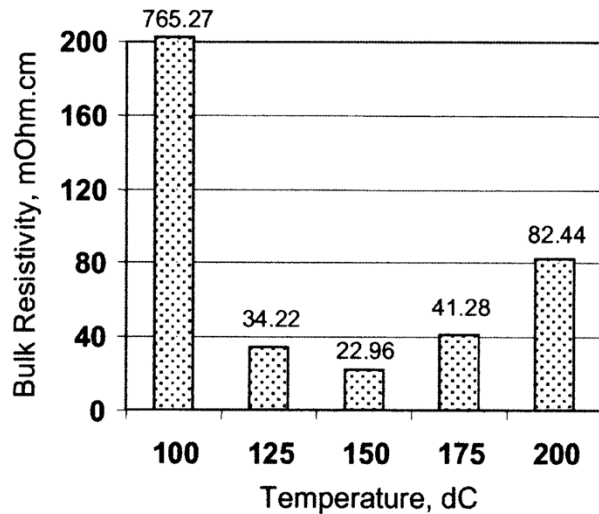
3.4 Cure Optimization

- **Removal of volatile organics**
 - **Organic liquids/solvents added**
 - **Viscosity control for printing**
- **Complete cure**
- **Polymer degradation**
- **Problems:**
 - **Bubbles**
 - **Ag particle/polymer delamination**

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Importance of optimized cure temperature Fan/Tison/Wong [ECTC 2002]

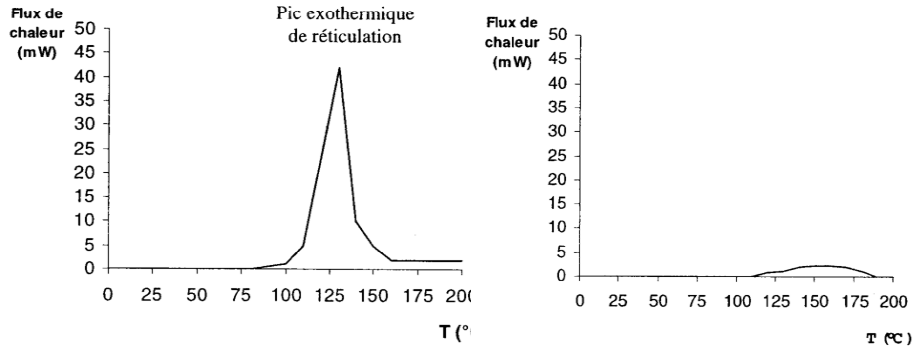


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Complete Cure (Th'set 1): DSC before & after cure

(Perichaud/Fremont)

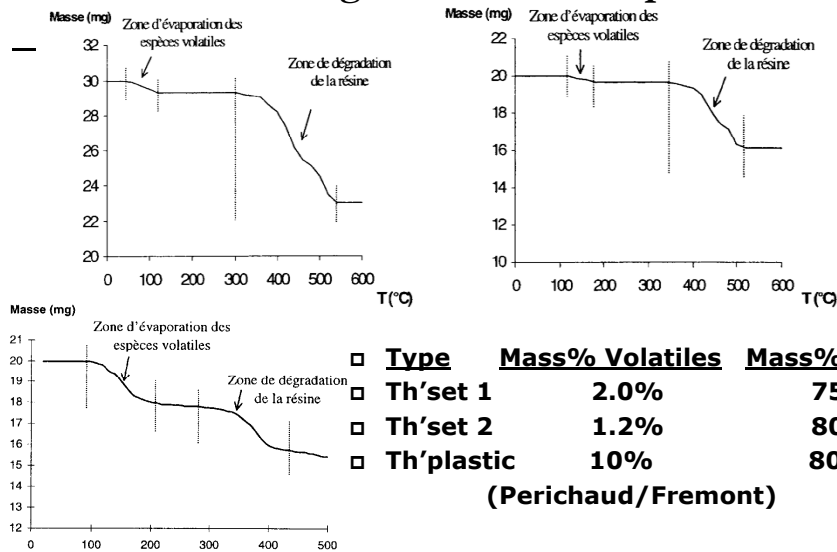


Use second DSC as measure of degree of cure - $\int_1 HdT / (\int_1 HdT + \int_2 HdT)$

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Thermogravimetric during cure: volatiles & degradation → composition



Type	Mass% Volatiles	Mass% Ag
Th'set 1	2.0%	75%
Th'set 2	1.2%	80%
Th'plastic	10%	80%

(Perichaud/Fremont)

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Cure Profile & Bubbles : 8175A

(Perichaud/Fremont)

